

United States Patent and Trademark Office



APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
10/633,149	07/31/2003	Ronnie P. Varghese	10020896-1	5430
7590 01/13/2005			EXAMINER	
AGILENT TECHNOLOGIES, INC.			TRAN, MAI HUONG C	
Legal Department, DL429 Intellectual Property Administration			ART UNIT	PAPER NUMBER
P.O. Box 7599			2818	· · · · · · · · · · · · · · · · · · ·
Loveland, CO	80537-0599		DATE MAILED: 01/13/200	5

Please find below and/or attached an Office communication concerning this application or proceeding.

		A	Annlicent(e)					
Office Action Summary		Application No.	Applicant(s)					
		10/633,149	VARGHESE, RONN	VARGHESE, RONNIE P.				
		Examin r	Art Unit					
		Mai-Huong Tran	2818					
	The MAILING DATE of this communication appears on the cover shet with the correspondence address Period for Reply							
THE - External after - If the - If NC - Failur Any	ORTENED STATUTORY PERIOD FOR REPL'MAILING DATE OF THIS COMMUNICATION. nsions of time may be available under the provisions of 37 CFR 1.1 SIX (6) MONTHS from the mailing date of this communication. period for reply specified above is less than thirty (30) days, a reply period for reply is specified above, the maximum statutory period or reply within the set or extended period for reply will, by statute reply received by the Office later than three months after the mailing and patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may within the statutory minimum of vill apply and will expire SIX (6) M cause the application to become	a reply be timely filed thirty (30) days will be considered timely. ONTHS from the mailing date of this com ABANDONED (35 U.S.C. § 133).	nmunication.				
Status								
1)⊠	Responsive to communication(s) filed on 22 D	ecember 2004.						
2a)□	This action is FINAL . 2b)⊠ This action is non-final.							
3)□	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
Disposit	ion of Claims							
5)□ 6)⊠ 7)□	 4) Claim(s) 1-19 is/are pending in the application. 4a) Of the above claim(s) 9-19 is/are withdrawn from consideration. 5) Claim(s) is/are allowed. 6) Claim(s) 1-8 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/or election requirement. 							
Applicat	ion Papers							
10)⊠	The specification is objected to by the Examine The drawing(s) filed on 31 July 2003 is/are: a) Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the Example 2015.	☑ accepted or b)☐ ob drawing(s) be held in abe tion is required if the draw	yance. See 37 CFR 1.85(a). ing(s) is objected to. See 37 CFF					
Priority (under 35 U.S.C. § 119		,					
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 								
2) Notice 3) Infor	et(s) ce of References Cited (PTO-892) ce of Draftsperson's Patent Drawing Review (PTO-948) ce of Draftsperson's Patent (s) (PTO-1449 or PTO/SB/08) cer No(s)/Mail Date	Paper I	w Summary (PTO-413) No(s)/Mail Date of Informal Patent Application (PTO- 	-152)				

Application/Control Number: 10/633,149

Art Unit: 2818

DETAILED ACTION

Election/Restriction

Application's election without traverse of Group I (Claims 1-8) drawn to a semiconductor device is acknowledged for prosecution in the subject application. Accordingly, claims 9-19 are withdrawn from consideration as being directed to a non-elected invention. See 37 CFR 1.142(b) and MPEP § 821.03.

Applicants have the right to file a divisional application covering the subject matter of the non-elected claims.

Claim Rejections - 35 U.S.C. § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

Claims 1-5 and 7-8 are rejected under 35 U. S. C. § 102 (e) as being anticipated by U.S. Patent No. 6,583,047 to Daniels et al.

Application/Control Number: 10/633,149

Art Unit: 2818

Regarding to claim 1, Daniels discloses a device comprising a first layer (fig. 1c), an etch stop layer (fig. 1c) positioned over the first layer; a second layer positioned over the etch stop layer (fig. 1c); a first trench positioned through the second layer, etch stop layer, and a portion of the first layer (col. 9, lines 65-67, col. 10, lines 1-67, and figs. 1(a)-1(h)).

Regarding to claim 2, Daniels discloses a device wherein the etch stop layer is an oxide (col. 13, lines 60-64).

Regarding to claim 3, Daniels discloses a device wherein the first layer is c-Si and the second layer is amorphous silicon (col. 10, lines 34-47).

Regarding to claim 4, Daniels discloses a device wherein the first layer is c-Si and the second layer is epitaxial silicon (col. 10, lines 34-47).

Regarding to claim 5, Daniels discloses a device wherein the first layer is low-k dielectric and the second layer is an amorphous Si (col. 10, lines 34-58).

Regarding to claim 7, Daniels discloses a device further comprising an intermediary layer interposing the etch stop layer and first layer, the trench further extending through the intermediary layer (fig. 7h).

Art Unit: 2818

Regarding to claim 8, Daniels discloses a device further comprising a second trench positioned through the second layer, etch stop layer, and a portion of the first layer, wherein the second trench has a shallower depth than the first trench (fig. 1h).

Claim Rejections - 35 U.S.C. § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claim 6 is rejected under 35 U.S.C. 103 (a) as being unpatentable over U.S. Patent No. 6,583,047 to Daniels et al. in view of the remark.

Regarding to this claim, Daniels discloses the claimed invention except for a device wherein k is between 1 and 3.9.

It would have been obvious to one of ordinary skill in the art at the time the invention was made to form a device wherein k is between 1 and 3.9, since it has been held that where the general conditions of a claim are disclosed in the prior art, discovering the optimum or working ranges involves only routine skill in the art. In re Aller, 105 USPQ 233.

Art Unit: 2818

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Mai-Huong Tran whose telephone number is (571)272-1796. The examiner can normally be reached on 8:00-4:30.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Nelms can be reached on (571)272-1787. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Mai-Huong Tran

Examiner Art Unit 2818